

UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION N	О.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/526,227		03/01/2005	Takakazu Miyahara	122462	6780	
25944	7590	04/07/2006		EXAMINER		
OLIFF & BERRIDGE, PLC P.O. BOX 19928				SCRUGGS, ROBERT J		
ALEXANDRIA, VA 22320		A 22320		ART UNIT	PAPER NUMBER	
				3723		
				DATE MAIL ED. 04/07/2006		

Please find below and/or attached an Office communication concerning this application or proceeding.

			e
	Application No.	Applicant(s)	
	10/526,227	MIYAHARA ET AI	- .
Office Action Summary	Examiner	Art Unit	
· · · · · · · · · · · · · · · · · · ·	Robert Scruggs	3723	
The MAILING DATE of this communication a Period for Reply	ppears on the cover sheet w	vith the correspondence ad	ldress
A SHORTENED STATUTORY PERIOD FOR REF WHICHEVER IS LONGER, FROM THE MAILING - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication If NO period for reply is specified above, the maximum statutory perions - Failure to reply within the set or extended period for reply will, by state that the period for reply will be set to be supported by the Office later than three months after the main period for the period for	DATE OF THIS COMMUN 1.136(a). In no event, however, may a od will apply and will expire SIX (6) MO tute, cause the application to become a	IICATION. a reply be timely filed DNTHS from the mailing date of this case ABANDONED (35 U.S.C. § 133).	
Status			
1) Responsive to communication(s) filed on 27	January 2006.		
·= · · _=	his action is non-final.		
3) Since this application is in condition for allow		tters, prosecution as to the	e merits is
closed in accordance with the practice unde	·		
Disposition of Claims			
4)⊠ Claim(s) <u>1-4</u> is/are pending in the application	n.		
4a) Of the above claim(s) none is/are withdra			
5) Claim(s) is/are allowed.			
6)⊠ Claim(s) <u>1-4</u> is/are rejected.			
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction and	d/or election requirement.		
Application Papers			
9) The specification is objected to by the Exami	iner.		
10)⊠ The drawing(s) filed on 27 January 2006 is/a	re: a)⊠ accepted or b)□	objected to by the Examin	er.
Applicant may not request that any objection to the			
Replacement drawing sheet(s) including the corr			FR 1.121(d).
11) The oath or declaration is objected to by the	Examiner. Note the attach	ed Office Action or form P	ГО-152.
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for forei	gn priority under 35 U.S.C.	§ 119(a)-(d) or (f).	
a) ☐ All b) ☐ Some * c) ☐ None of:			
1. ☐ Certified copies of the priority docume	ents have been received.		
2. Certified copies of the priority docume		Application No	
3. Copies of the certified copies of the pr	riority documents have bee	n received in this National	Stage
application from the International Bure			
* See the attached detailed Office action for a	ist of the certified copies no	ot received.	
Attachment(s)			
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) 		v Summary (PTO-413) o(s)/Mail Date	
Information Disclosure Statement(s) (PTO-1449 or PTO/SB/	T	f Informal Patent Application (PT	O-152)
Paper No(s)/Mail Date	6) Other: _		

DETAILED ACTION

1. This office action is in response to amendment received on January 27, 2006.

Claim Rejections - 35 USC § 102/103

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (a) the invention was known or used by others in this country, or patented or described in a printed publication in this or a foreign country, before the invention thereof by the applicant for a patent.
- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claims 1-4 are rejected under 35 U.S.C. 102(b) as anticipated by or, in the alternative, under 35 U.S.C. 103(a) as obvious over Rutherford et al. (5692950). Rutherford et al. discloses an apparatus for polishing an optical disk comprising, a rotatable polished body holder for holding a polished body (Column 9, Lines 3-65), a rotatable polishing body holder (Column 9, Lines 3-65) for holding a polishing body (Figure 1) (24), a buffer member (14) provided between the polishing body and the polishing body holder, a rigid member (22) provided between the buffer member and the polishing body holder (Column 5, Lines 1-11), a driver for rotationally driving the polishing body holder and/or the polished body holder, and a pressing unit for pressing the polishing body holder and the polished body holder against each other with the predetermined contact pressure (Column 9, Lines 3-65). The examiner notes that since

Rutherford et al. discloses the same material (i.e. polyurethane, Column 8, Lines 24-27), thickness (i.e. 1-2 mm thick, Column 7, Lines 33-36) and pressure (i.e. 3-20 kPa, Column 10, Lines 8-10) as disclosed by the applicant in the specification, therefore since the properties of Rutherford et al. and the applicant are the same the deformation of the buffer member would inherently fall within the disclosed range of 0.1mm-0.2mm.

5. Assuming arguendo, if the deformation of the buffer member is not seen as falling within the disclosed range of 0.1mm-0.2mm, it would have been obvious to modify the polishing pad of Rutherford et al. containing the properties (i.e. thickness, pressure and material) as disclosed by the applicant, since Rutherford et al. teaches of including those previously mentioned properties falling within wider ranges than disclosed by the applicant, in order to obtain the required amount of deformation of the buffer member as desired by a user during various applications.

Response to Arguments

6. Applicant's arguments with respect to claims 1-4 have been considered but are moot in view of the new ground(s) of rejection.

Conclusion

7. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Keipert (5962120), Bauer (6547657) and Hutchins (4671020) all disclose devices having a buffer member that is elastically deformable and including a rigid member located behind said buffer member for providing a stiff backing.

Art Unit: 3723

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Robert Scruggs whose telephone number is 571-272-8682. The examiner can normally be reached on Monday-Friday, 8:30-5:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Joseph Hail can be reached on 571-272-4485. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

ంకల్లిగి J. Hail, III Supervisory Patent Examiner Technology Center 3700

Justo Haite